



THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : Confirmation No. 9635
Satoshi MAEMORI et al. : Docket No. 2001_1300A
Serial No. 09/955,111 : Group Art Unit 1752
Filed September 19, 2001 : Examiner Sin Lee

POSITIVE-WORKING PHOTORESIST
COMPOSITION AND PHOTOSENSITIVE
MATERIAL USING SAME

PETITION FOR EXTENSION OF TIME

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Petition hereby is made for a three month extension of time to respond to the communication of September 5, 2003.

The fee of \$950.00 is
 submitted herewith.
 to be charged to Deposit Account No. 23-0975. A duplicate copy of this Petition is enclosed.

 Small entity status of this application is established by a Small Entity Status Assertion which
 is enclosed.
 has been previously submitted.

Respectfully submitted,

Satoshi MAEMORI et al.

By Matthew M. Jacob
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March 4, 2004

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